PATENT Customer No. 22,852 Attorney Docket No. 04329.2802-01

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	)
Mari INOUE	) Parent Group Art Unit: 2813
Rule 1.53(b) Division of Application No. 10/107,247 filed March 28, 2002	) Parent Examiner: C. Thompson )
Filed: Herewith	)
For: A METHOD FOR CORRECTING A DESIGN DATA OF A LAYOUT PATTERN OF A PHOTOMASK, PHOTOMASK MANUFACTURING BY SAID METHOD, AND SEMICONDUCTOR DEVICE METHOD USING SAID PHOTOMASK	<b>,</b>
Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450	
Sir:	

## PRELIMINARY AMENDMENT

Please amend the above-identified patent application as follows:

Amendments to the Specification are included in this paper.

Amendments to the Claims are reflected in the listing of claims in this paper.

FINNEGAN HENDERSON FARABOW GARRETT & DUNNERLLP

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